

# Numerical simulation and optimization of CdS/p-Si Heterojunction solar cells

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**Abstract.** In this paper, numerical simulation was made to analyze and optimize the important factors of CdS/p-Si heterojunction solar cell, which include work function of TCO layers and back surface field (BSF), thickness of CdS thin film and silicon substrate. The results of simulation indicated that the TCO work function is supposed to be lower than 4.4 eV, while the work function of BSF is supposed to be higher than 4.8 eV. The improper TCO work function is found to be the cause of the reverse electric field. The improper BSF work function also affects the solar cell performance, but does not cause the reverse electric field. The thickness of the CdS thin films has an important influence on the electrical performance of CdS/p-Si solar cell, the VOC and JSC decrease as the thickness of CdS thin film increases. Undoped CdS/p-Si solar cells were fabricated by thermal evaporation and the PCE of 10.63% was measured under standard condition after partial structure optimization of CdS/p-Si solar cell (the area of cell is 1cm<sup>2</sup>). The difference between the simulation and experiment result is discussed.

## Introduction

Crystalline silicon solar cells have the advantages of high efficiency and mature technology. However, the wafers must go through several high temperature processes during cell fabrication. In addition, thin film solar cells such as a-Si/ $\mu$ -Si, CdTe, CIGS consume less raw materials and have lower cost, whereas their power conversion efficiency (PCE) is lower than crystalline silicon solar cells. The combination of crystalline silicon solar cells and thin film solar cells has become an interesting research direction to avoid their shortcomings. Heterojunction (HJ) solar cells based on crystalline silicon wafers draw a worldwide attention for the lower temperature processing. Different materials such as CdS [1, 2], ZnS [3], ZnO [4], AZO [5], ITO [6], WO<sub>3</sub> [7, 8], MoO<sub>3</sub> [9, 10] have been applied as the emitter of HJ solar cells. Among these materials, the PCE of silicon based HJ solar cells exceeded 25% [11, 12] with doped a-Si:H thin film as the emitter, which demonstrates the potential of HJ solar cells.

CdS is a widely used window layer material for solar cells [13, 14] with an energy band ( $E_g$ ) of 2.42 eV. It has better short wavelength transparency than the a-Si:H thin film ( $E_g$  about 1.7 eV). The best efficiency of CdS/Si HJ solar cell reported so far is 11.3%, which was measured under a light

intensity of  $45 \text{ W/m}^2$ , and the solar cell area was  $0.16 \text{ cm}^2$  [2]. The same research group reported later that the  $1 \text{ cm}^2$  CdS/Si solar cell yielded a PCE of 10.6% under standard test condition of AM1.5,  $1000 \text{ W/m}^2$  and  $25^\circ\text{C}$  [1]. However, the simulation analysis of CdS/Si HJ solar cells has not been reported. In this work, we simulate and optimize some structure parameters of CdS/Si HJ solar cells. The PCE of CdS/Si HJ solar cell was improved by the assist of numerical simulation.

## Simulation details

The simulation is performed by AFORS-HET v.2.4 [15], which focuses on HJ solar cell simulation [16]. It is processed under the steady-state calculation model (DC-model) and standard illumination condition of AM1.5, 300K. Work functions of the TCO and the back surface field (BSF) are discussed. The thickness of CdS thin film and silicon substrate are researched. Table 1 gives the main parameters used for the simulation.

Table 1 Main simulation parameters in CdS/Si HJ solar cell

parameters	n-CdS	p-Si
Thickness ( $\mu\text{m}$ )	0.02	200
Dielectric constant	8.9	11.9
Electron affinity (eV)	4.05	4.05
Bandgap (eV)	2.42	1.12
Optical bandgap (eV)	2.42	1.12
Effective conduction band density ( $\text{cm}^{-3}$ )	$1.5 \times 10^{18}$	$2.8 \times 10^{19}$
Effective valance band density ( $\text{cm}^{-3}$ )	$1.8 \times 10^{19}$	$2.7 \times 10^{19}$
Electron mobility ( $\text{cm}^2 \cdot \text{Vs}^{-1}$ )	50	1041
Hole mobility ( $\text{cm}^2 \cdot \text{Vs}^{-1}$ )	20	412.9
Doping concentration acceptors ( $\text{cm}^{-3}$ )	0	$1.5 \times 10^{16}$
Doping concentration donators ( $\text{cm}^{-3}$ )	$6 \times 10^{18}$	0
Electron thermal velocity ( $\text{cm} \cdot \text{s}^{-1}$ )	$1 \times 10^7$	$1 \times 10^7$
Hole thermal velocity ( $\text{cm} \cdot \text{s}^{-1}$ )	$1 \times 10^7$	$1 \times 10^7$
Layer density ( $\text{g} \cdot \text{cm}^{-3}$ )	4.826	2.328
Auger electron recombination coefficient ( $\text{cm}^6 \cdot \text{s}^{-1}$ )	0	$2.2 \times 10^{-31}$
Auger hole recombination coefficient ( $\text{cm}^6 \cdot \text{s}^{-1}$ )	0	$9.9 \times 10^{-32}$
Band to band recombination coefficient ( $\text{cm}^3 \cdot \text{s}^{-1}$ )	0	0

## Results and discussions

Work function of TCO layer in HJ solar cells is known to be crucial for the performance of solar cells. The influence of work function of TCO layer on CdS/Si solar cells was evaluated. The variation of open-circuit voltage ( $V_{\text{OC}}$ ), short-circuit current density ( $J_{\text{SC}}$ ), fill factor (FF) and PCE as the function of work function of TCO layer for CdS/Si solar cells is depicted in Fig.1. The dash red line means the flat band condition when the TCO layer has the same work function as CdS layer. The results show that all the parameters of the CdS/Si solar cell decrease with the work function of TCO increasing.  $J_{\text{SC}}$  decreases gradually as the work function increases.  $V_{\text{OC}}$  and FF drop dramatically when the value of work function exceeds 4.4 eV. As a result, PCE of the CdS/Si solar cells is highly affected when the work function of TCO layer is higher than 4.4 eV.

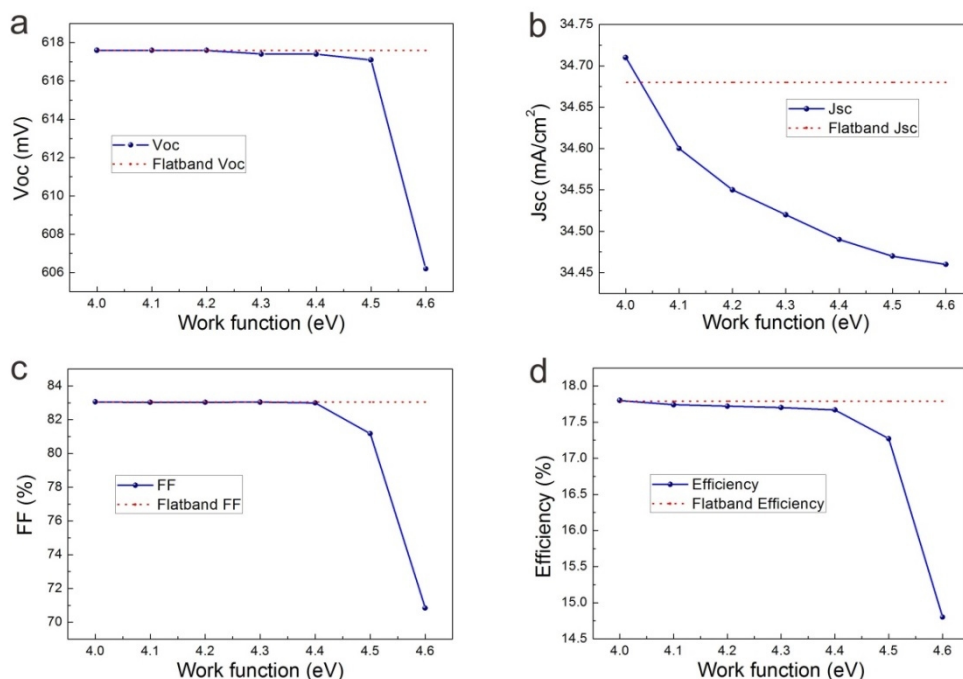


Fig.1 The variation trends of CdS/Si solar cell parameters caused by different TCO work function.

As shown in Fig.2a, the J-V curve is obviously affected when the TCO work function reaches 4.5 eV, which means the formation of reverse electric field. When the work function is up to 4.6 eV, the reverse electric field is so strong that the J-V curve is no longer a typical rectification curve. The energy band diagram shows that the TCO layer with work function at 4.6 eV caused serious reversion (Fig. 2b). This result means that the reverse electric field is a detrimental factor when the TCO work function is too high.

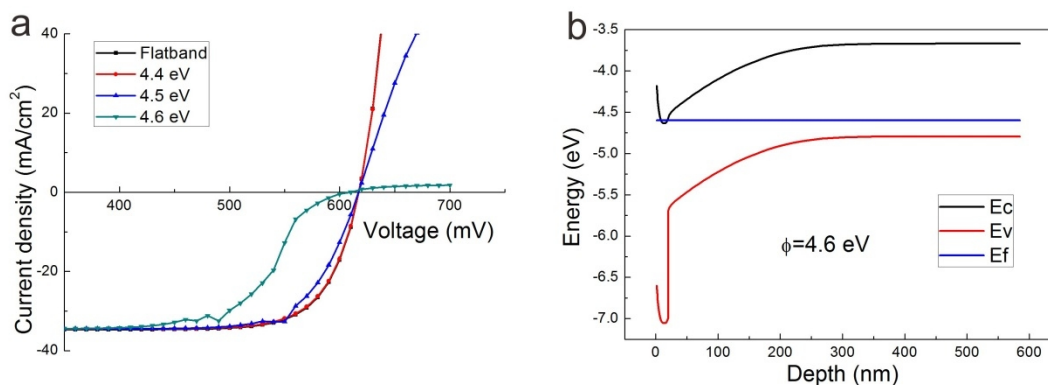


Fig.2 The J-V curves and energy band of CdS/Si solar cell with different TCO work function.

Effects of the work function of BSF on parameters of CdS/Si solar cell were researched. The VOC, FF and PCE of CdS/Si solar cell increase when the work function of BSF becomes higher (Fig.3). The improvement is prominent when the work function of BSF is lower than 4.8 eV. But the parameters show little improvement when the work function further increases beyond 4.8 eV. JSC is not affected by the work function of BSF.

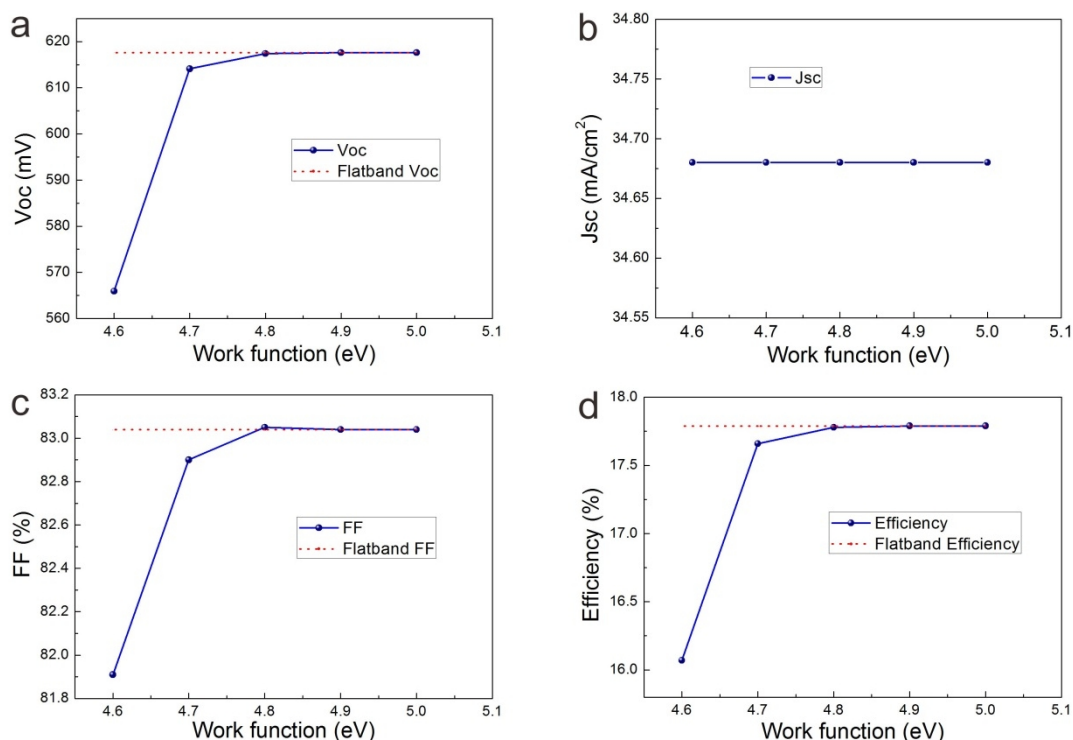


Fig.3 Effects of the work function of back contact on parameters of CdS/Si solar cell.

In contrast to the effect of TCO in the front surface, the BSF does not change the shape of the J-V curve which still shows the shape of a typical rectification curve (Fig.4). This means that although the parameters of the solar cell are obviously affected by the BSF, the J-V curves do not show the reverse electric field.

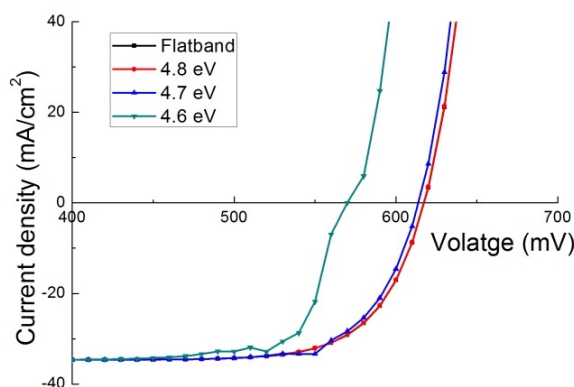


Fig.4 Effects of the work function of back contact on the J-V curves of CdS/Si solar cell.

The influence of thickness of CdS thin film on efficiency and other parameters of CdS/Si solar cell is also simulated (Fig.5). The values of VOC and JSC decrease gradually with thickness of CdS thin film increasing, while the FF stays stable as the CdS thickness varies. As a result, the PCE drops from 17.8% to 16.4% as the thickness of CdS thin film increases from 20 nm to 200 nm.

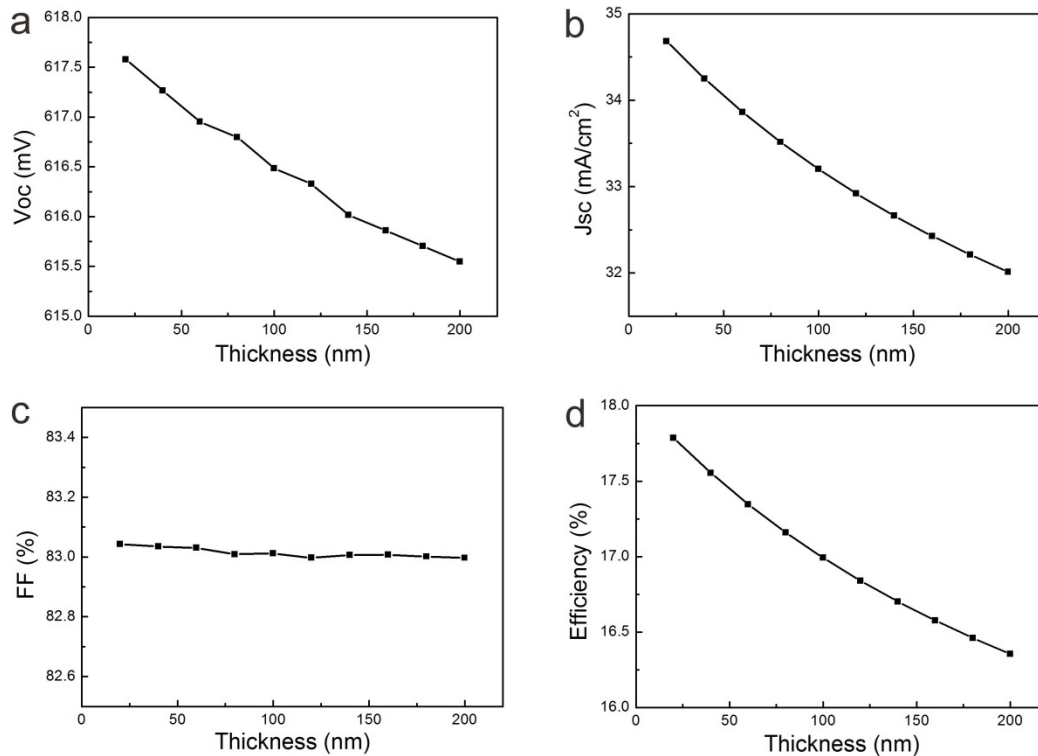


Fig.5 Influence of CdS thickness on the solar cell parameters

The external quantum efficiency (EQE) is affected as the thickness of CdS thin film increase (Fig.6(a)). The affected wavelength range is from 300 nm to 500 nm, which indicates that the CdS thin film causes the parasitic optical absorption in short wavelength range. According to the simulation results, thickness of the CdS thin film should be as thin as possible. But in the fabrication, CdS thin films less than 10 nm is very likely to be discontinuous. The favorable thickness is among 15 nm to 20 nm. The EQE results in Fig.6(b) show that thicker silicon substrates possess better absorption in visible and ultraviolet spectrum.

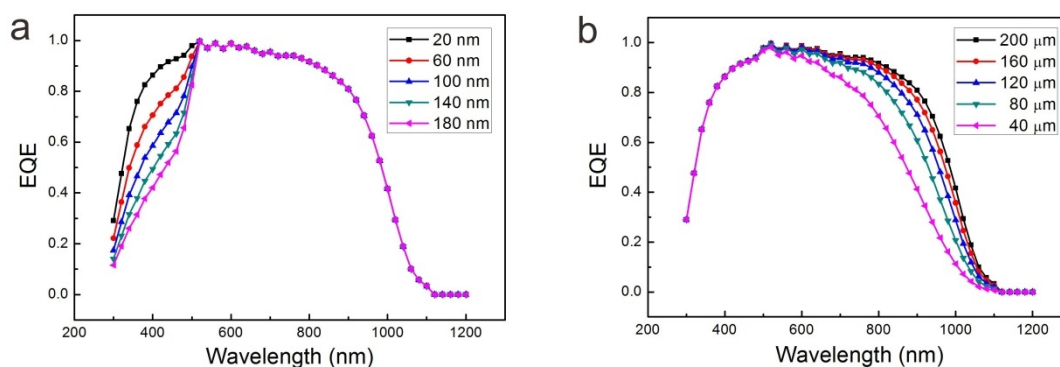


Fig.6 The EQE spectrum of CdS/Si solar cell with different CdS and Si thickness.

CdS/p-Si HJ solar cell at a size of 1 cm×1 cm was fabricated. CdS thin films were deposited on the front surface of the polished p-type monocrystalline silicon substrate by vacuum thermal evaporation. High work function material of MoO<sub>3</sub> was deposited on the rear side of the solar cell to form the BSF. The thickness and performance of CdS thin film, TCO and BSF were optimized. In the end, under the condition of 25 °C, AM 1.5 test, the PCE of 10.63% has been possessed for Ag/In<sub>2</sub>O<sub>3</sub>/n-CdS/p-Si/MoO<sub>3</sub>/Ag HJ solar cell with 40 nm thick CdS film. JSC, VOC, and FF are

28.75 mA·cm<sup>-2</sup>, 543 mV, and 68.13 %, respectively. Comparing to the simulation results, the PCE of CdS/p-Si HJ solar cell can be further increased. The difference between experimental and simulation results is mainly because the texture and passivation process is lacked during the fabrication. Both JSC and VOC are supposed to be improved with the presence of these steps. Also, the thin film preparation process still has room to be improved.

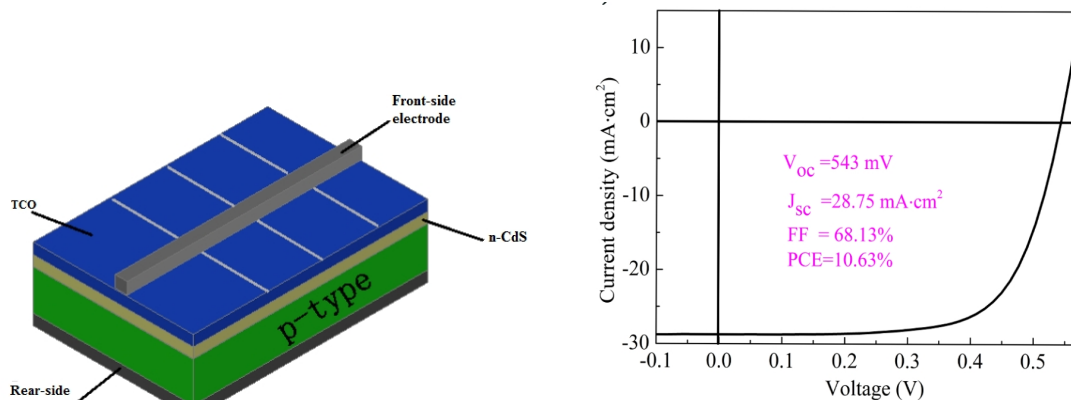


Fig.7 Schematic structure and J-V curve of CdS/Si solar cell

## Conclusions

The CdS/Si HJ solar cells were analyzed by AFORS-HET. The work function of TCO and BSF were researched. Simulation results indicated that the TCO work function is supposed to be lower than 4.4 eV, and the work function of BSF is supposed to be higher than 4.8 eV. The energy band diagram indicates that the TCO layer causes reverse electric field in the HJ solar cell when the work function is higher than 4.5 eV. The CdS thin film is supposed to be lower than 20 nm to reduce the parasitic optical absorption in the short wavelength range. The CdS/Si HJ solar cell was fabricated and the efficiency was 10.63% in 1 cm<sup>2</sup> area. Texturing and passivation is needed to further improve the efficiency of the CdS/Si solar cells.

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